2825



PATENT Customer No. 22,852 Attorney Docket No. 04329.2306

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:	)			
Yoshio Ozawa, et al.	) Group Art Unit: 2823			
Application No.: 09/559,757	Examiner: Pham, Thanh V.			
Filed: April 27, 2000	) )			•
For: METHOD OF MANUFACTURING A SEMICONDUCTOR DEVICE USING AN OXIDATION PROCESS (As Amended Hereby)	) ) ) )	TECHNOL OG	SEP	REC
Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450		Y CENTER 2	22 2333	RECEIVED
Sir:		900		

## **AMENDMENT**

In reply to the Office Action of June 24, 2003, with a period for response extending through September 24, 2003, please amend the application as follows. Applicants also respectfully request the Examiner's reconsideration in view of the remarks that follow:

Amendment to the Title is shown on page 2.

Amendments to the Specification are shown on page 3.

Amendments to the Drawings are made in the attached replacement sheets and are discussed in the Remarks section of this paper.

Remarks begin on page 4.

FINNEGAN HENDERSON FARABOW GARRETT & DUNNER LLP

1300 I Street, NW Washington, DC 20005 202.408.4000 Fax 202.408.4400 www.finnegan.com

Application Number: 09/559,757 Filing Date: April 27, 2000

Attorney Docket Number: 04329.2306

## **AMENDMENT TO THE TITLE:**

Please amend the title of the application as follows. On page 1, please replace the title at line 2 with the following title:

SEMICONDUCTOR DEVICE AND METHOD OF MANUFACTURING THEREOF A

SEMICONDUCTOR DEVICE USING AN OXIDATION PROCESS

FINNEGAN HENDERSON FARABOW GARRETT & DUNNER LLP

1300 I Street, NW Washington, DC 20005 202.408.4000 Fax 202.408.4400 www.finnegan.com